



Docket: P910218

*IFW*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Chin-Cheng Yang

Serial No.: 10/668,698

Filed: September 23, 2003

For: METHODS FOR FORMING A  
PHOTORESIST PATTERN USING AN  
ANTI-OPTICAL PROXIMITY EFFECT

Examiner: Le Dung Anh

Group Art 2818

Unit:

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service, First Class mail, postage prepaid, in an envelope addressed to Mail Stop Non-Fee Amendment, Commissioner of Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on November 10, 2004.  
STOUT, UXA, BUYAN & MULLINS, LLP

Kenton R. Mullins, Reg. No. 36,331

TRANSMITTAL

Sir:

Submitted herewith are

- ~ Amendment (12 pages including 1 sheet of drawings and this Transmittal);
- ~ The Commissioner is hereby authorized to charge any needed fees to deposit account 50-1600.

Respectfully submitted,

Date: November 10, 2004

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